

## IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Application of:  
Nguyen, et al.

Serial No.: 09/912,103

Confirmation No.: 4476

Filed: July 23, 2001

For: Selective Etching of Organosilicate  
Films Over Silicon Oxide Stop Etch  
LayersMAIL STOP AF  
Commissioner for Patents  
P.O. Box 1450  
Alexandria, VA 22313-1450

Dear Sir:

§ Group Art Unit: 2823

§ Examiner: Khiem D. Nguyen

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CERTIFICATE OF FAX  
37 CFR 1.8

I hereby certify that this correspondence and the documents referred to as attached therein are being facsimile transmitted to the U.S. Patent and Trademark Office to the fax number indicated by the Examiner, namely, fax number 703-872-9306 to the attention of the named Examiner, on the date below.

1/6/05

Date

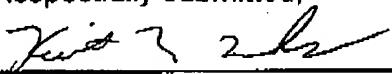
Khiem D. Nguyen

Signature

## STATEMENT OF COMMON OWNERSHIP

The present application (Serial No. 09/912,103; hereinafter the "Application"), and Patent No. 6,777,171, Xu et al., were, at the time the invention of the Application was made, owned by the same person, or subject to an obligation of assignment to the same person, Applied Materials, Inc.

Respectfully submitted,

  
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